



#181B

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE
(Attorney Docket No. 4492P1090US; Client No. P97-0011)

Applicant: Ritzdorf, Thomas L.

For: SEMICONDUCTOR PLATING SUPPORT HAVING WORKPIECE
ENGAGING ELECTRODE WITH PRE-CONDITIONED CONTACT
FACE

Serial No.: 08/940,686

Filed: September 30, 1997

Examiner: William Leader

Art Unit: 1741

RECEIVED
2001 FEB 22 AM 9:39
BOARD OF PATENT APPEALS
AND INTERFERENCES

RESPONSE TO OFFICE ACTION DATED OCTOBER 3, 2000

Assistant Commissioner for Patents
Washington, D.C. 20231

RECEIVED
1000 11
TECHNOLOGY CENTER 1700

Dear Sir:

In response to the Office Action mailed October 3, 2000, with a one-month extension, please amend the application in the following manner.

IN THE CLAIMS:

1. (Amended) [A microelectronic workpiece holder] An apparatus for use in [a microelectronic] electroplating [apparatus used to plate] a metal that is principally comprised of a metal X [or metals] onto a [microelectronic workpiece] wafer pursuant to fabricating microelectronic components on the wafer, the holder comprising:
a reactor adapted to hold an electrolyte that is used to electroplate the metal that is principally comprised of the metal X;